

Please replace paragraph [0012] on page 3 with the following rewritten paragraph:

-- Figure 1 illustrates an exemplary substrate 20, which has been prepared using the method

of the present invention. In exemplary embodiments the substrate is a metal substrate, preferably manufactured from stainless steel. It will be appreciated that other metals may be suitable, for example, brass, silicon, or other. The substrate 20 is coated with a thin film, preferably parylene.

B2 A pattern 22 is then etched into the substrate 20. The etched portion is removed, leaving windows with the film in the etched portion. An exemplary method for creating the substrate with windows with film as shown in Figure 1 is illustrated in Figure 2 and described below. --